

**INFORMATION DISCLOSURE  
CITATION FORM FOR  
PATENT APPLICATION  
(FORM PTO-1449)  
(Substitute)**

Docket No.: 02W026

Serial No.:

Applicant(s): Jack et al.

Filing Date: herewith

Group:

**U.S. PATENT DOCUMENTS**

Examiner Initials	Document Number (Number-Kind Code)	Publication Date (MM-DD-YYYY)	Name of Patentee or Applicant	Class	Sub-class
FP	US-5,399,897	03-21-1995	Cunningham et al.	257	467
FP	US-5,450,053	09-12-1995	Wood	338	18
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**FOREIGN PATENT DOCUMENTS**

Examiner Initials	Document Number (Country Code-Number-Kind Code)	Publication Date (MM-DD-YYYY)	Name Of Patentee of Applicant	Translation? Yes/No/n/a
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**OTHER DOCUMENTS (Author (Capitalize), Title, Date, Pages, Etc., if known)**

FP	"Pulsed Electron Deposition (PED) ", www.neocera.com for PED (pulsed electron
	deposition), web pages printed 4/28/03, 3 pages

Examiner's Signature:

Date Considered:

Initial if reference was considered, whether or not citation is in conformance with MPEP. Mark through citation if not considered.  
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